

**Form 1449 (Modified)****Information Disclosure
Statement By Applicant**

(Use Several Sheets if Necessary)

Atty Docket No. SYMXP010
Application No.: 10/642,386
Inventor WANG, Youqi et al.
Group Unassigned
Filing Date August 15, 2003
Mailing Date November 14, 2003

U.S. Patent and Published Documents

Examiner Initial	No.	Patent No.	Date	Patentee	Class	Sub- Class	Filing Date
an	A	4,956,067	09/1990	Yun et al.	204	212	1/4/1990
	B	5,985,356	11/1999	Schultz et al.	427	8	10/18/1994
	C	6,045,671	04/2000	Wu et al.	204	298.11	4/22/1997
	D	6,187,164	02/2001	Warren et al.	205	81	7/20/1998
	E	6,364,956	04/2002	Wang et al.	118	726	1/26/1999
	F	6,455,316	09/2002	Turner et al.	436	37	4/13/2000
an	G	6,468,806	10/2002	McFarland et al.	436	518	9/30/1997

Foreign Patent or Published Foreign Patent Application

Examiner Initial	No.	Document No.	Publication Date	Country or Patent Office	Class	Sub- class	Translation	
an	H	WO 98/14641	4/9/1998	WO			Yes	No
an	I	WO 00/17413	3/30/2002	WO				
an	J	WO 02/48841	6/20/2002	WO				

Other Documents

Examiner Initial	No.	Author, Title, Date, Place (e.g. Journal) of Publication
an	K	Schmidt et al., "Rotating Disk Electrode Measurements on the CO Tolerance of a High-Surface Area Pt/Vulcan Carbon Fuel Cell Electrocatalyst," Journal of the Electrochemical Society (1999), 146(4), 1296-1304
	L	Schmidt et al., "Characterization of High-Surface-Area Electrocatalysts Using a Rotating Disk Electrode Configuration" Journal of the Electrochemical Society (1998), 145(7), 2354-2358
	M	"Rotating Disk Electrode for Voltammetry" Metrohm Ltd, Metrohm Ion Analysis, December 1995
	N	"BAS RDE-2 Rotating Disk Electrode" wysiwyg://12/http://www.bioanalytical.com/products/ec/rde-2.html , April 15, 2003
	O	"Electrochemistry Refresher" http://www.bath.ac.uk/~chascf/java/electrochemistry/elec/17html/hydro.htm ,
an	P	Bard, Allen J. et al., "Electrochemical Methods, Fundamentals and Applications", Chapter 8, pp. 280-312, 1980

Examiner: *Ch. Noyes* Date Considered: *01/13/2007*

Examiner: Initial citation considered. Draw line through citation if not in conformance and not considered.
Include copy of this form with next communication to applicant.